

Form PTO-1449
(Rev. 8-83)U.S. Department of Commerce
Patent and Trademark Office

Atty Docket 0756-2394

Serial No. Unassigned

INFORMATION DISCLOSURE STATEMENT

Applicants: Hongyong ZHANG et al.

Filing Date:

Group Art Unit:
Unassigned

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| Examiner Initial | Document Number | Date | Name | Class | Subclass | Filing Date (if appropriate) |
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| F rm PTO-1449 (Rev. 8-83) | | U.S. Department of Commerce Patent and Trademark Office | | Atty Docket 0756-2394 | | Serial No. Unassigned | |
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| INFORMATION DISCLOSURE STATEMENT | | Applicants: Hongyong ZHANG et al. | | | | | |
| | | Filing Date: | | Group Art Unit: Unassigned | | | |
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| Examiner | <i>Bruce Kehinde</i> | | Date Considered | <i>July 2, 2003</i> | | | |
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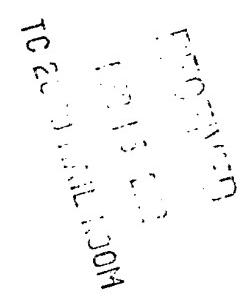
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| Examiner <i>Bonon Kebell</i> | | | | Date Considered <i>July 2, 2003</i> | | | |

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| | | Filing Date: November 27, 2001 | | Group Art Unit: 2823 | | |
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(Rev. 8-83)U.S. Department of Commerce
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Atty Docket 0756-2394

Serial No. 09/993,492

INFORMATION DISCLOSURE STATEMENT

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Filing Date: November 27, 2001

Group Art Unit: 2823

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